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JCE68 U.S. PRO
10/067265
02/07/02

LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT

ATTY. DOCKET NO.: P67585US0 GROUP ART UNIT: Not Yet Assigned
SERIAL NO.: Not Yet Assigned FILING DATE: February 7, 2001
APPLICANT(S): Jun Dong KIM, et al. TODAY'S DATE: February 7, 2001

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	INT'L CLASS	SUB- CLASS	FILING DATE (If Appropriate)
<u>AKS</u>	<u>AA</u>	<u>5,256,248</u>	<u>10/26/93</u>	<u>Young-Kwon Jun</u>	<u>H01L</u>	<u>21/00 10/13/92</u>
<u>AKS</u>	<u>AB</u>	<u>6,184,081</u>	<u>02/06/01</u>	<u>Jeng, et. al</u>	<u>H01L</u>	<u>21/336 10/08/99</u>
<u>AKS</u>	<u>AC</u>	<u>6,008,131</u>	<u>12/28/99</u>	<u>Chao-Cheng Chen</u>	<u>H01L</u>	<u>21/302 12/22/97</u>
<u>AKS</u>	<u>AD</u>	<u>5,880,035</u>	<u>03/09/99</u>	<u>Seiichi Fukuda</u>	<u>H01L</u>	<u>21/302 04/25/97</u>
<u>AKS</u>	<u>AE</u>	<u>5,087,535</u>	<u>02/11/92</u>	<u>Hirokane, et al.</u>	<u>G03F</u>	<u>9/00 02/27/87</u>
<u>AKS</u>	<u>AF</u>	<u>4,495,220</u>	<u>01/22/85</u>	<u>Wolf, et al.</u>	<u>H01L</u>	<u>21/312 10/07/83</u>
<u>AKS</u>	<u>AG</u>	<u>5,286,674</u>	<u>02/15/94</u>	<u>Roth, et al.</u>	<u>H01L</u>	<u>21/44 03/02/92</u>

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION (YES) (NO)
<u>AKS</u>	<u>AH</u>	<u>08-321484</u>	<u>12/03/96</u>	<u>Japan</u>	<u>H01L</u> <u>21/3065</u> <u>X</u>
<u>AKS</u>	<u>AJ</u>	<u>09-082797</u>	<u>03/28/97</u>	<u>Japan</u>	<u>H01L</u> <u>21/768</u> <u>X</u>
	<u>AK</u>	<u>09-260347</u>	<u>03/10/97</u>	<u>Japan</u>	<u>H01L</u> <u>21/306</u> <u>X</u>
	<u>AL</u>	<u>11-087322</u>	<u>03/30/99</u>	<u>Japan</u>	<u>H01L</u> <u>21/3065</u> <u>X</u>

EXAMINER

Asdu Kumar Sarthar

DATE CONSIDERED

1/22/03

* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant(s).